

IN THE CLAIMS:

Please CANCEL claims 1-13 without prejudice to or disclaimer of the recited subject matter.

Please ADD new claims 14-19, as follows. For the Examiner's convenience, all claims currently pending in this application have been reproduced below:

1-13. (Cancelled)

14. (New) A reflection type mask comprising:

a substrate on which a multi-layered film for reflecting X-rays is provided;

a mask pattern which is formed on said multi-layered film for absorbing the X-rays; and

a cover for protecting said mask pattern, wherein said cover is detachably attached to said substrate.

15. (New) A reflection type mask according to claim 14, further comprising an alignment mark formed on said multi-layered film.

16. (New) A reflection type mask according to claim 14, further comprising an alignment mark, wherein said cover protects said alignment mark.

17. (New) A reflection type mask according to claim 16, wherein said alignment mark is formed on said multi-layered film.

18. (New) A reflection type mask according to claim 14, wherein said cover includes an air through-hole.

19. (New) A reflection type mask according to claim 18, wherein said air through-hole is formed on a side surface of said cover.